

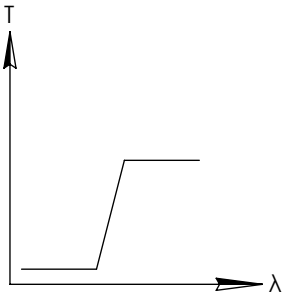
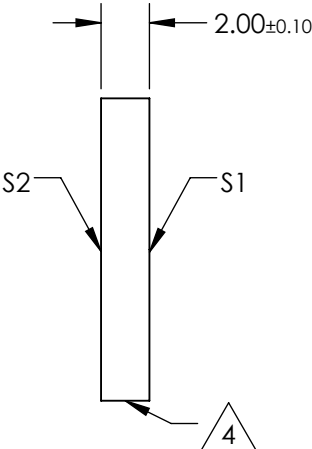
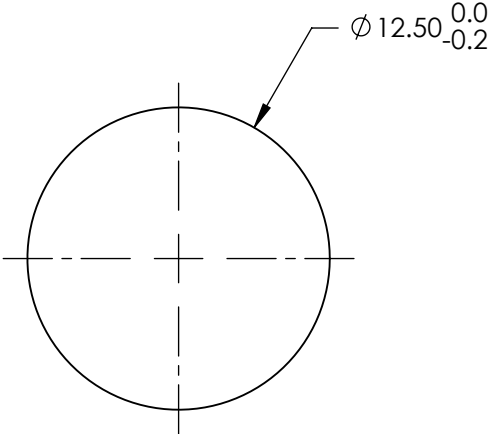
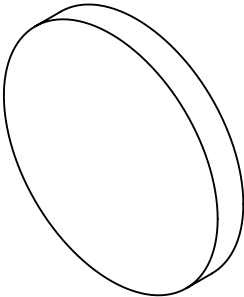
**FOR INFORMATION ONLY:
DO NOT MANUFACTURE
PARTS TO THIS DRAWING**

NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 408 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 390nm @ 0° AOI
T(abs): =50% FOR 400±4nm @ 0° AOI
S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 400nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO		62974	SHEET 1 OF 1

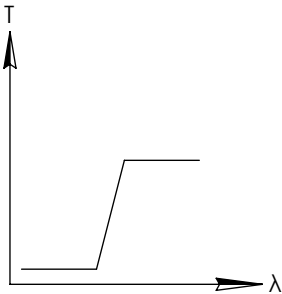
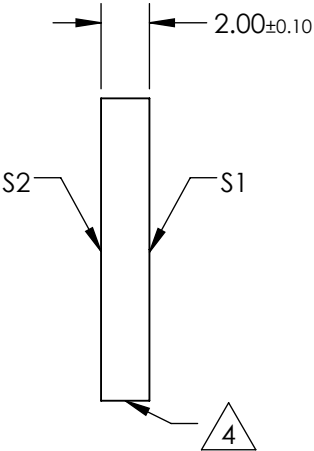
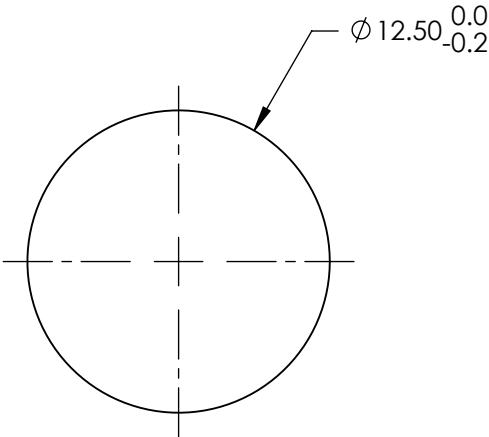
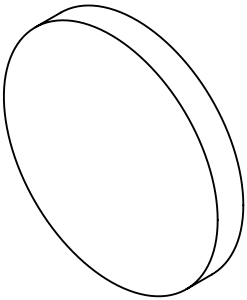
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NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 458 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 440nm @ 0° AOI
T(abs): =50% FOR 450±4.5nm @ 0° AOI
- S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 450nm, HIGH PERFORMANCE LONGPASS FILTER
		DWG NO	62975
		SHEET 1 OF 1	

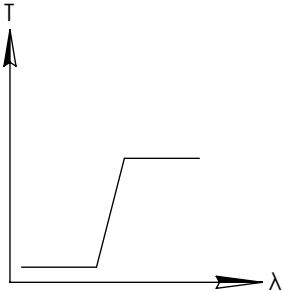
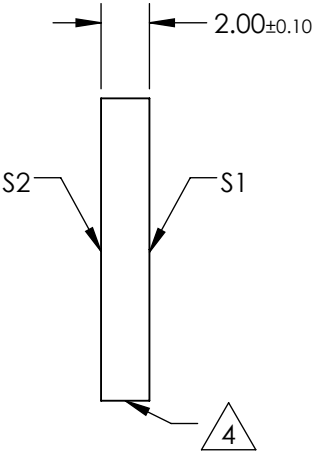
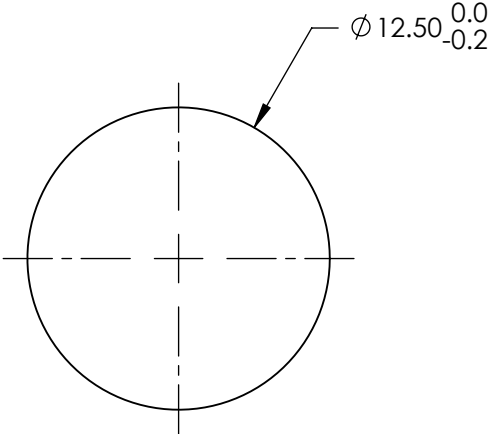
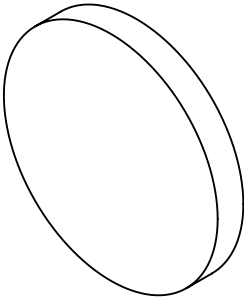
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NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
 - S1: HARD DIELECTRIC SPUTTERED
 - T(avg): ≥91% FROM 508 - 1650nm @ 0° AOI
 - T(avg): ≤0.01% FROM 200 - 490nm @ 0° AOI
 - T(abs): =50% FOR 500±5nm @ 0° AOI
 - S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 500nm, HIGH PERFORMANCE LONGPASS FILTER
		DWG NO	62976
		SHEET 1 OF 1	

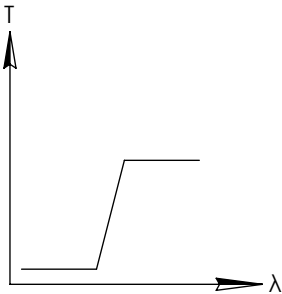
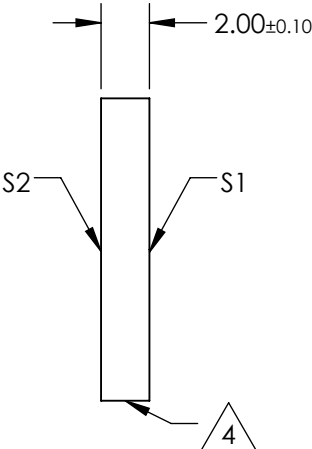
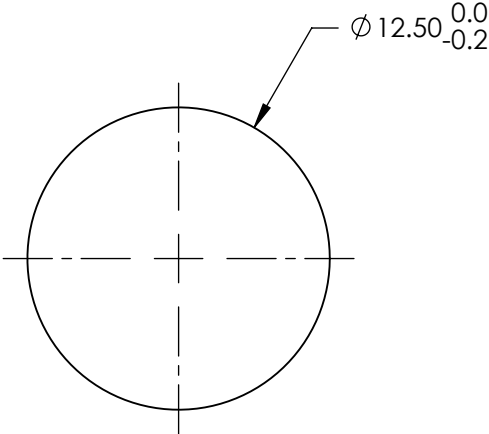
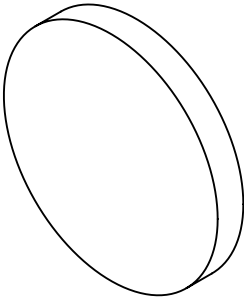
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PARTS TO THIS DRAWING**

NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 560 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 539nm @ 0° AOI
T(abs): =50% FOR 550±5.5nm @ 0° AOI
- S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 550nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO		62977	SHEET 1 OF 1

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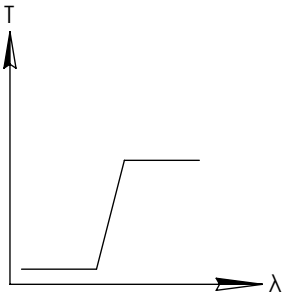
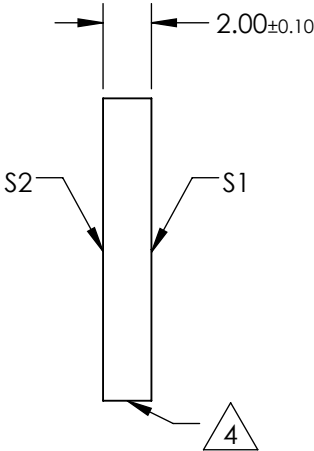
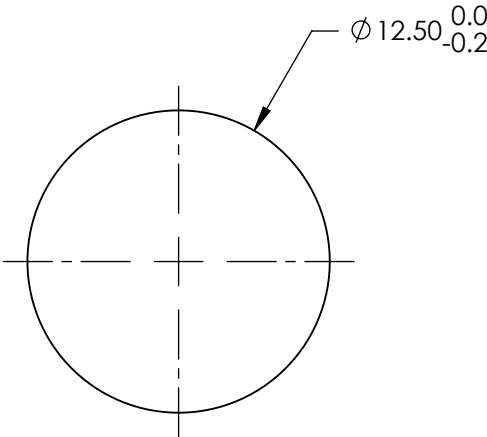
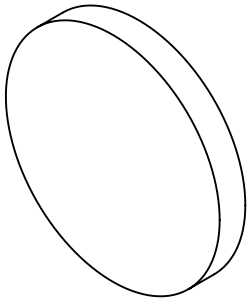
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 610 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 588nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 600 \pm 6nm @ 0° AOI

S2:SINGLE LAYER MgF2

 FINE GRIND SURFACE

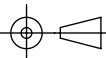
5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION 		TITLE		Ø12.5mm, 600nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	62978	SHEET 1 OF 1	

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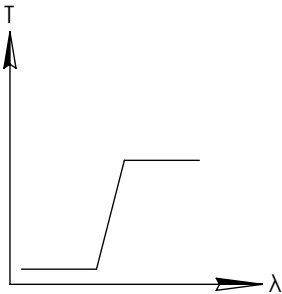
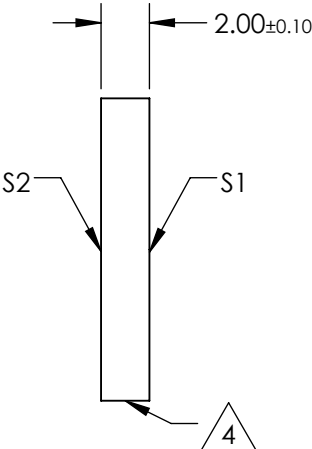
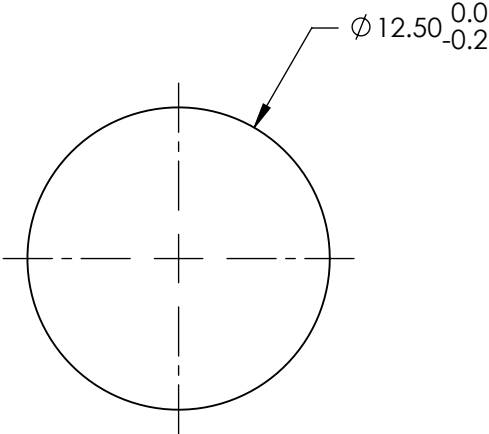
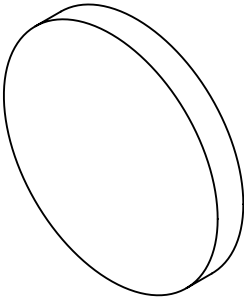
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NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 660 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 637nm @ 0° AOI
T(abs): =50% FOR 650±6.5nm @ 0° AOI
- S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN		TITLE	Ø12.5mm, 650nm, HIGH PERFORMANCE LONGPASS FILTER
mm		DWG NO	62979
			SHEET 1 OF 1

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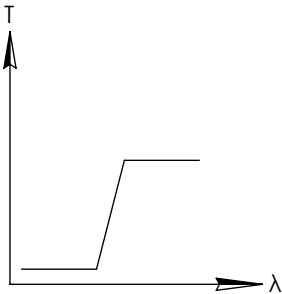
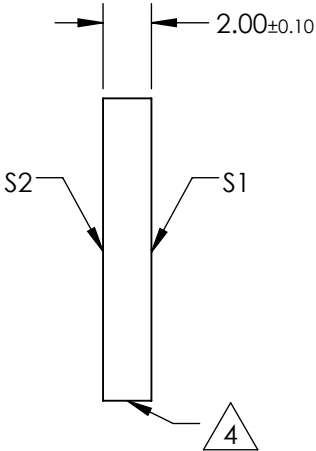
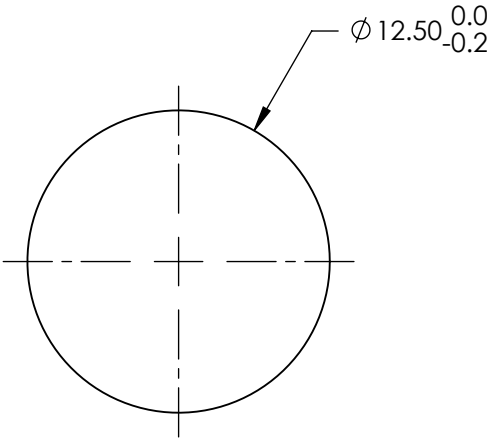
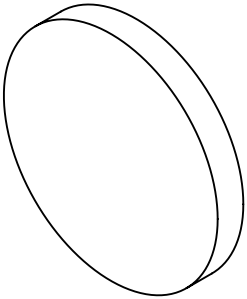
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 765 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 735nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 750 \pm 7.5nm @ 0° AOI

S2: SINGLE LAYER MgF2

 FINE GRIND SURFACE

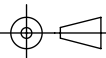
5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION 		TITLE		Ø12.5mm, 750nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	66226	SHEET 1 OF 1	

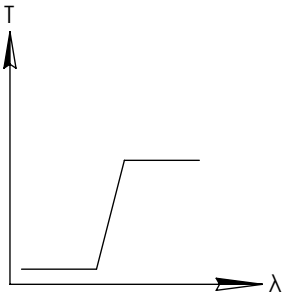
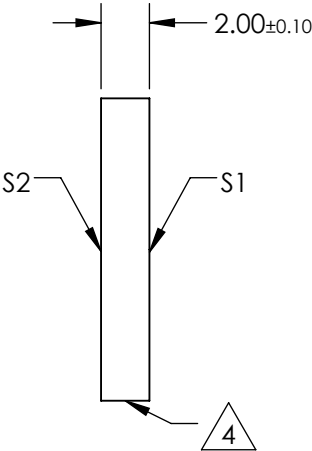
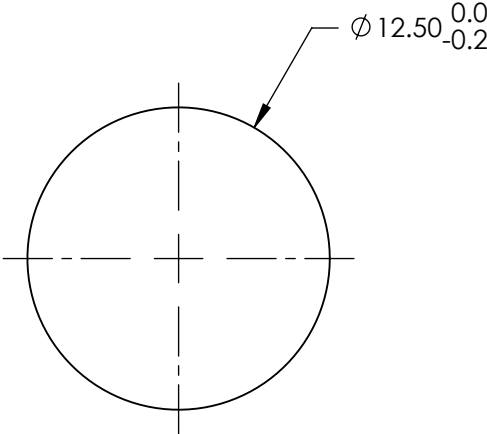
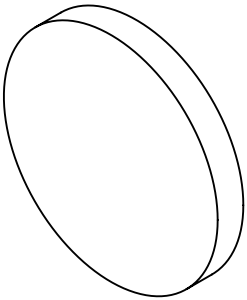
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NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 765 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 735nm @ 0° AOI
T(abs): =50% FOR 750±7.5nm @ 0° AOI

S2:SINGLE LAYER MgF2
4. FINE GRIND SURFACE
5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 750nm, HIGH PERFORMANCE LONGPASS FILTER
		DWG NO	66226
		SHEET 1 OF 1	

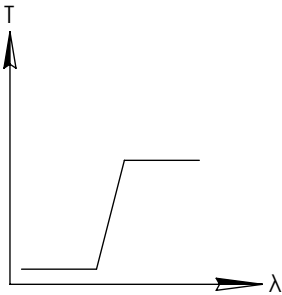
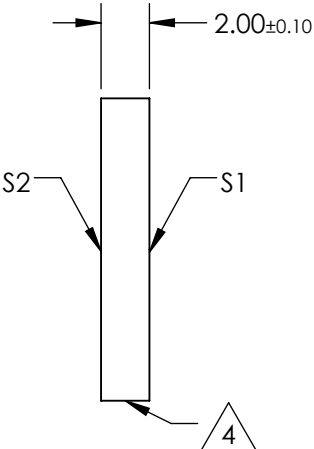
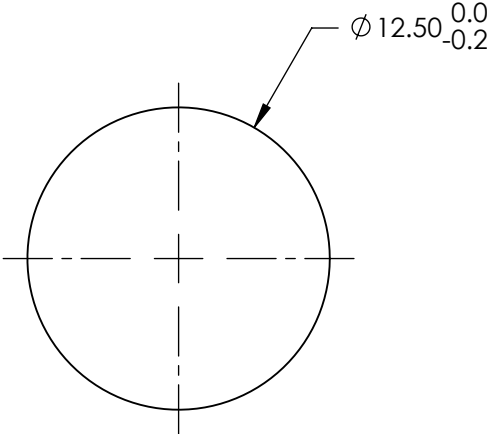
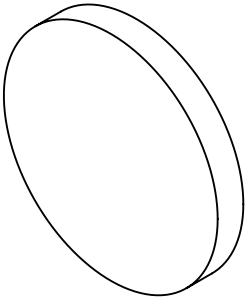
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NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
 - S1: HARD DIELECTRIC SPUTTERED
 - T(avg): ≥91% FROM 815 - 1650nm @ 0° AOI
 - T(avg): ≤0.01% FROM 200 - 785nm @ 0° AOI
 - T(abs): =50% FOR 800±8nm @ 0° AOI
 - S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 800nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO		66227	SHEET 1 OF 1

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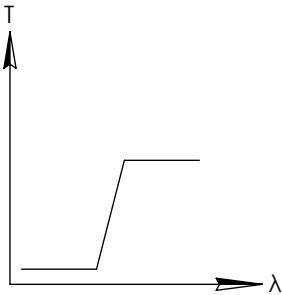
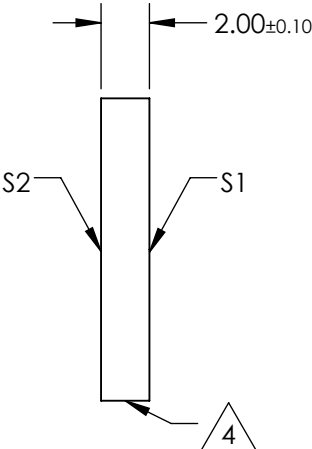
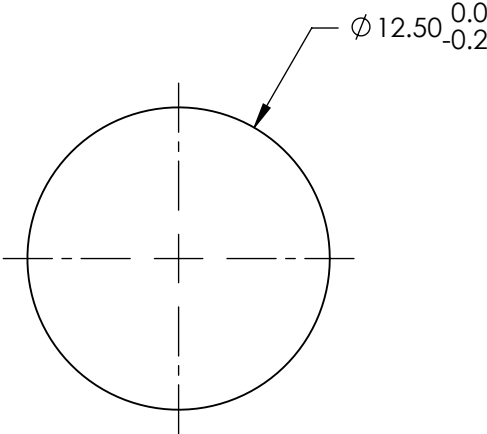
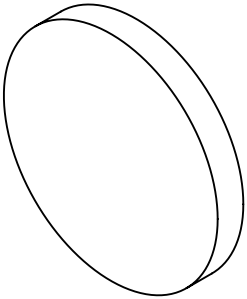
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 865 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 835nm @ 0° AOI
T(abs): =50% FOR 850±8.5nm @ 0° AOI

S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 850nm, HIGH PERFORMANCE LONGPASS FILTER
		DWG NO	66228
		SHEET 1 OF 1	

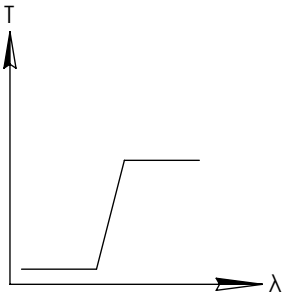
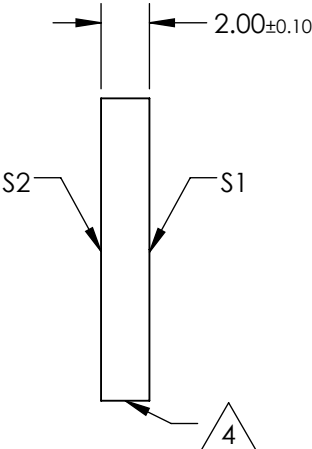
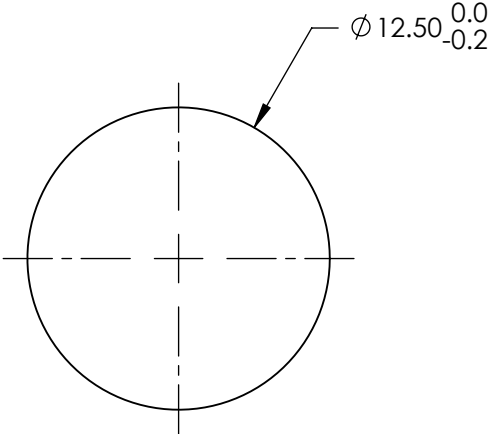
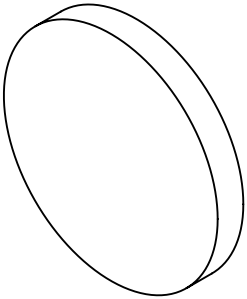
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NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
 - S1: HARD DIELECTRIC SPUTTERED
 - T(avg): ≥91% FROM 915 - 1650nm @ 0° AOI
 - T(avg): ≤0.01% FROM 200 - 880nm @ 0° AOI
 - T(abs): =50% FOR 900±9nm @ 0° AOI
 - S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 900nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO		66229	SHEET 1 OF 1

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PARTS TO THIS DRAWING**

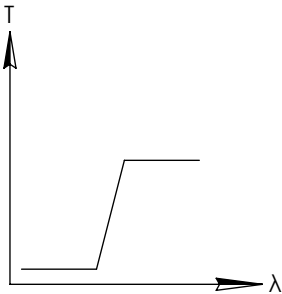
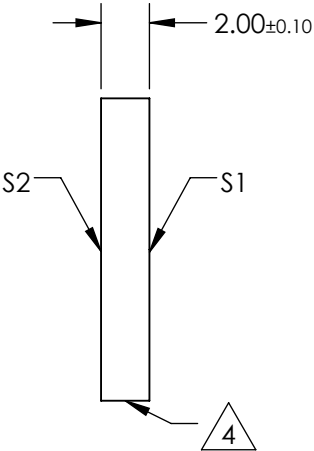
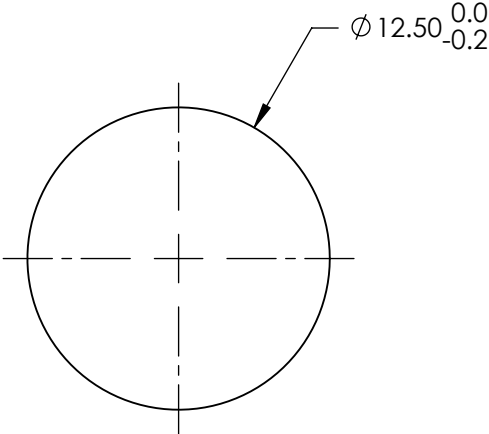
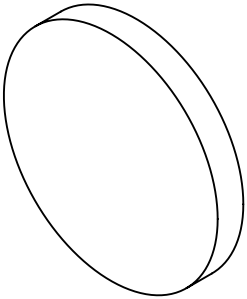
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 965 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 930nm @ 0° AOI
T(abs): =50% FOR 950±9.5nm @ 0° AOI

S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		TITLE		Ø12.5mm, 950nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	66230	SHEET 1 OF 1	

Edmund Optics®

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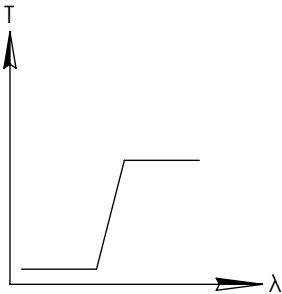
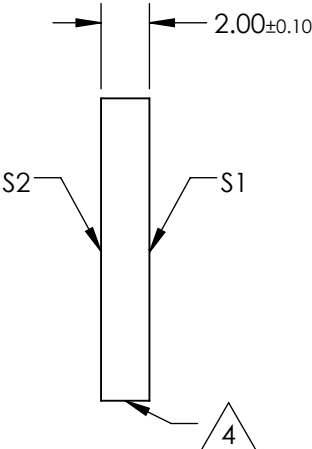
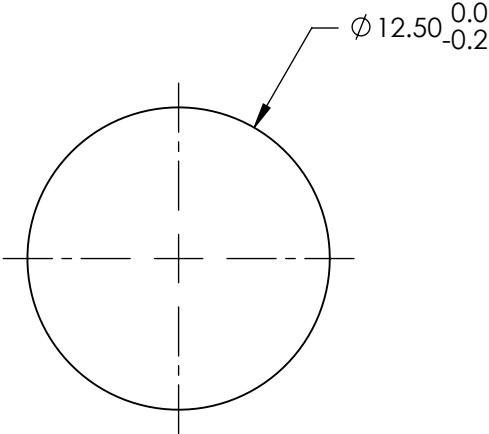
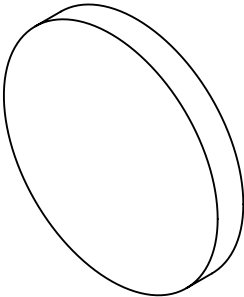
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 1020 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 980nm @ 0° AOI
T(abs): =50% FOR 1000±10nm @ 0° AOI

S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 1000nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO		66231	SHEET 1 OF 1

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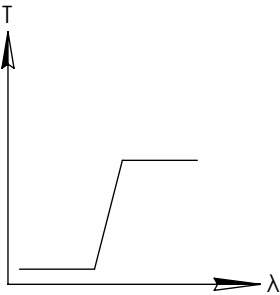
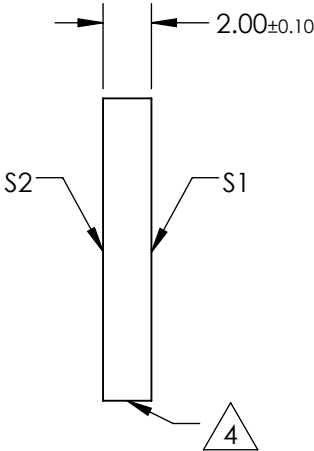
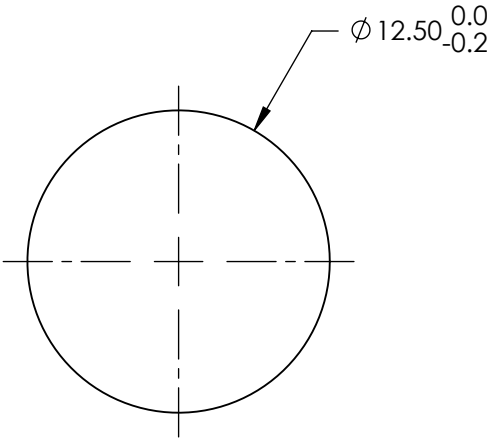
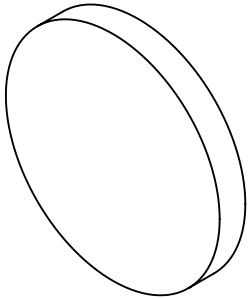
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 1070 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 1030nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 1050 \pm 10.5nm @ 0° AOI

S2: SINGLE LAYER MgF2

 FINE GRIND SURFACE

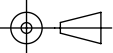
5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT




LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION 

ALL DIMS IN	mm
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 Edmund Optics®	
TITLE	Ø12.5mm, 1050nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO	66232
SHEET 1 OF 1	

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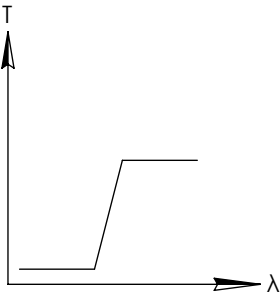
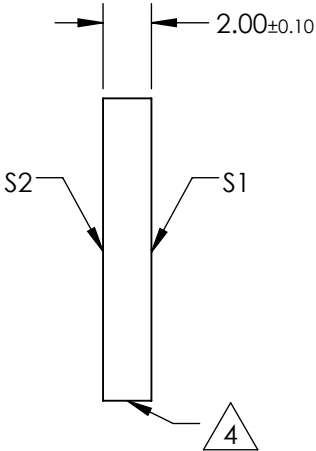
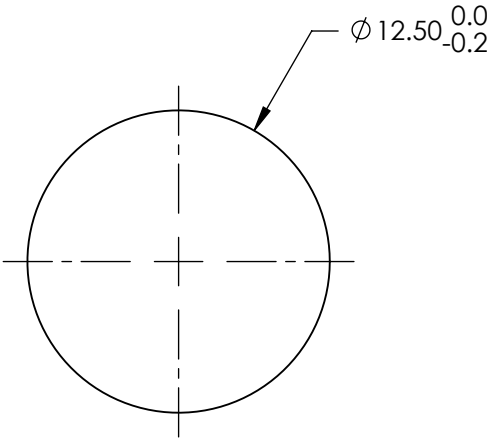
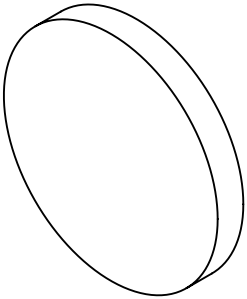
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 1120 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 1080nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 1100 \pm 11nm @ 0° AOI

S2: SINGLE LAYER MgF2

 FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED



ALL DIMS IN mm

 **Edmund Optics®**

TITLE	Ø12.5mm, 1100nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO	66233
SHEET	1 OF 1